plate or methyl methacrylate copolymer. Polymer(s) corresponding (I) absorbs near infrared ray selectively. Using (I), (II) or (III), to (A) and (B) are blended to become (B) content in (I) to 0.07-1.07 (1) an optical filter(II) for plasma display comprising (I) and one of electrically conductive layer, antistatic layer or reflection insulating (2) an optical filter(III) for plasma display comprising (I) or (II) and (A) is film(s) or sheet(s) of methyl methacrylate homopolymer clear image of plasma display is obtained, errors of electrical and electronic instruments can be avoided by using (I), (II) or (III) A(4-F1A, 12-L3D) E(5-L2C) G(6-A3, 6-A11, 6-F4, 6glass plate or plastic plate(s) to support (I) or (II). R1-R4= H or methoxy independently. Also claimed, are: **EMBODIMENT ADVANTAGE** F5) L(3-G5) layer; and \*JP 11012425-A MITR 97.06.23 Optical filter(I) for plasma display comprising (A) and (B) is claimed. 97.06.23 97JP-165923 (99.01.19) C08L 33/00, C08K 5/36, C09K 3/00, G02B 5/22, H01J 11/02, F21V 9/04, C08K 5/56 // C08J 5/00 (A): acrylic resin film(s) or sheet(s) (B): nickel complex(es) of A89 E23 G06 L03 Optical filter for plasma display. MITSUBISHI RAYON CO LTD C99-044043 99-148685/13 formula (I):

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(I) or (II) is formed on glass or plastic plate(s) 0.39 g/m<sup>2</sup> to obtain (I). (I) showed transmittance 15 % at 920 nm, 68 (B1), cpd. R1-R4= p-methoxy in formula (1), was added to Acrypet VH(RTM), the mixt. was moulded to film containing (B1) g/m<sup>2</sup>, the mixt. moulded to film(s) or sheet(s) to obtain (I). One of layer), antistatic layer(e.g. surface active agent layer) or reflection electrically conductive layer(e.g. silver thin layer and/or ITO thin insulating layer(e.g. silica layer, titania layer etc) is formed on (I) surface to obtain (II). (I) or (II) is formed on glass or plastic plat % at 450-680 nm region. (4pp129DwgNo.0/0) **EMBODIMENT** to obtain (III).